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FORM: PTO-1449 U.S. DEPARTMENT OF COMMERCE Atty Docket No: Serial No: (REV: 7-80) 1998-0609.02/US PATENT AND TRADEMARK OFFICE Applicant: INFORMATION DISCLOSURE STATEMENT BY APPLICANT Micron Technology, Inc. Filing Date: Group: November 25, 2003 (37 CFR 1.98(b)) (use several sheets if necessary) -Not Assigned

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